Synthesis of 2D Transition Metal Oxides

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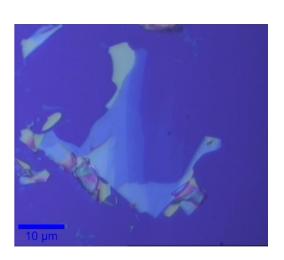
Abstract

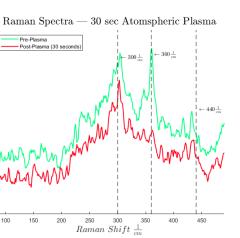
- The goal of this FURI project is to synthesize thin film transition metal oxides. Metal oxides have known bulk properties but some have not been synthesized in a thin film forms. Materials take on vastly different properties when they are on the nano-scale.
- Nanomaterials have been utilized in many ways such as batteries, insulation, medicine, transportation, and optics^[1].
- The hypothesis of this project is that thin film transition metal oxides of germanium dioxide (GeO₂), hafnium dioxide (HfO₂), and palladium dioxide (PdO₂) can be synthesized based on previous research by the Wang research group^[2]. Their results show that molybdenum trioxide (MoO₃) and tungsten trioxide (WO₃) can be synthesized from their respective sulfides MoS₂ and WS₂ by atmospheric plasma treatment in the form of thin-flake nanomaterials.

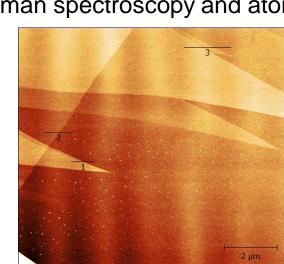
First Semester Results

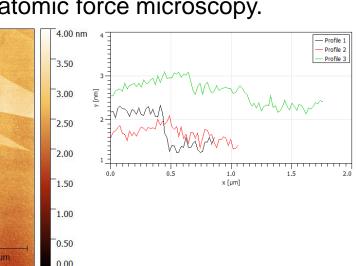
Synthesis of GeS₂ Flakes

Referencing an article on material synthesis of thin flakes[3] mechanical exfoliation of GeS₂ was found to be most favorable by plasma treating substrates to be hydrophilic and exposing samples to 100 °C heat for one minute before cleaving. This produced thin flakes that are characterized by Raman spectroscopy and atomic force microscopy.







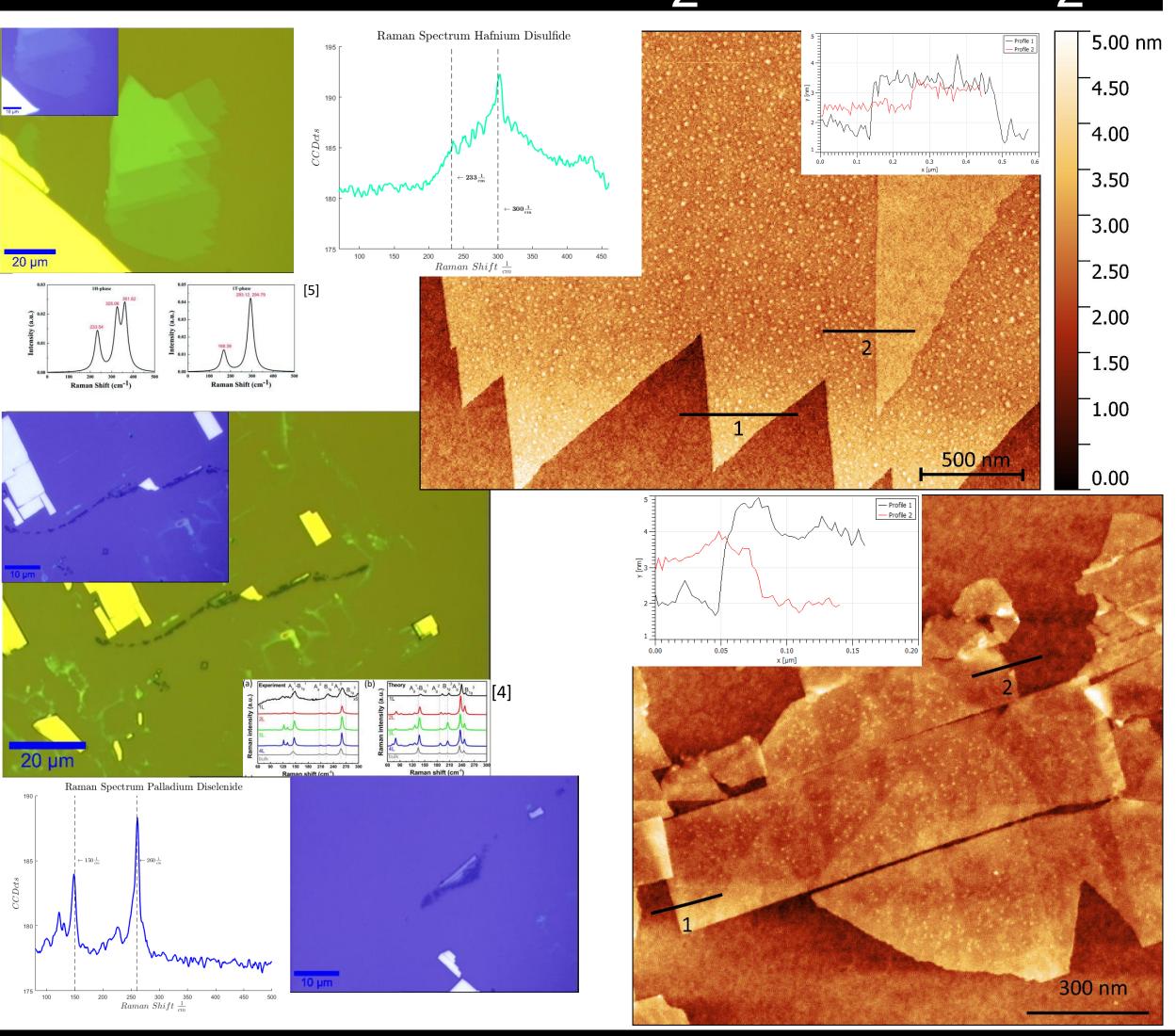


Current Research

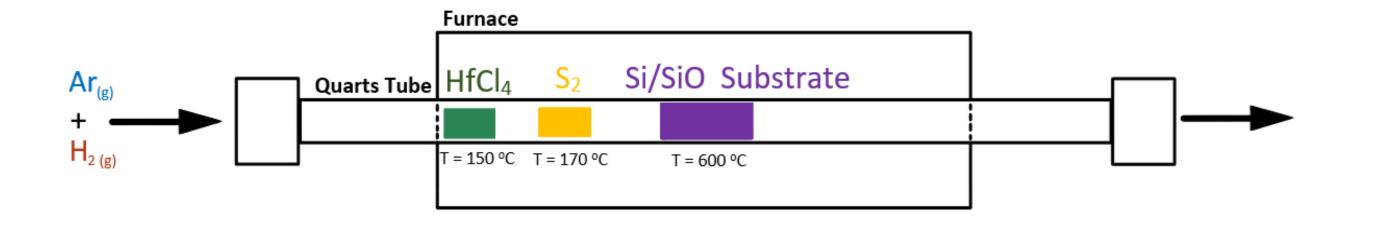
Synthesis of HfS₂ and PdSe₂ Flakes

- Using the same synthesis techniques for mechanical exfoliation of HfS2 and PdSe2 was found to yield the largest area and highest-quality flakes by exposing pre-exfoliated samples to 100 °C hot plate for one minute and cleaving while the substrates were hot.
- Thin flakes are characterized by Raman spectroscopy and atomic force microscopy.
- Complications arose with both HfS₂ and PdSe₂
- HfS₂ is very unstable in air as a thin film. Within one-hour, thin film samples found and characterized with Raman were disintegrated by the time atomic force microscopy (AFM) was performed.
- Chemical vapor deposition (CVD) could lead to less reactive HfS₂ 2D flakes.
- Initial HfS₂ CVD results indicate possible vertical morphology that is being investigated.
- PdSe₂ has yielded small single or double layer 1-micron by 1-micron flakes.
- High quality exfoliated PdSe₂ flakes are too small to characterize with Raman spectroscopy but have been imaged using AFM.

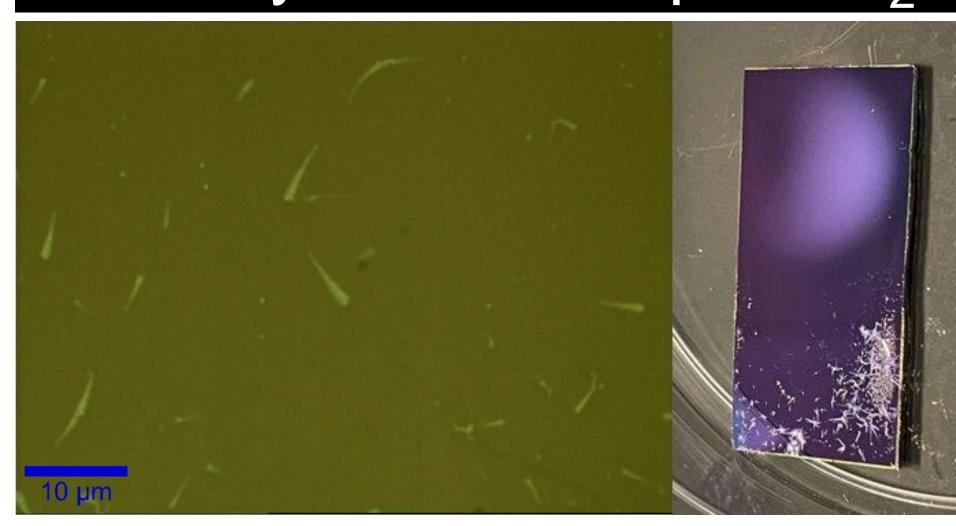
Exfoliation of HfS₂ and PdSe₂



Chemical Vapor Deposition (CVD) HfS₂



CVD Synthesis Steps HfS₂



Synthesis of HfS₂ via Chemical Vapor Deposition

· Hafnium disulfide was also made using a method called chemical vapor deposition. A mixture of argon (50 sccm) and hydrogen (15 sccm) gas are passed into a tube furnace made of quarts at ambient pressure. They carry vaporized hafnium chloride (24 mg) and sulfur (196.9 mg) into the center of the chamber where the substrate is heated to 600 °C. A chemical reaction takes place that results in deposited hafnium sulfide on the surface. The outcome was possibly vertically growing thin flakes but more experimentation is required to achieve usable thin flakes. This growth process is being refined to produce thin flakes suitable for air plasma treatment.

Future Work

Plasma Treatment of 2D Transition Metal Dichalcogenides

- Thin flakes of HfS₂ and PdSe₂ are nearing a level of quality and size to be treated with air plasma to test the hypothesized method for synthesizing transition metal oxides. Once these ideal flakes are achieved the methods used from the first semester on GeS₂ will be used on HfS₂ and PdSe₂.
- Air plasma treatments to 2D transition metal dichalcogenides are hypothesized to create 2D transition metal oxides.

References

[1] Nano Technology Initiative 2000, accessed September 26th, 2020, <https://www.nano.gov/you/nanotechnology-benefits>

[2] Chu, X. S., Li, D. O., Green, A. A., Wang, Q. H. (2017). Formation of MoO₃ and WO₃ nanoscrolls from MoS₂ and WS₂ with atmospheric air plasma. *Journal of Materials Chemistry C., Vol.(*5) pg 11301 - 11309. DOI: 10.1039/c7tc02867a

[3] Yuan, Huang, et al, (2015). Reliable Exfoliation of Lare-Area High-Quality Flakes of Graphene and Other Two-Dimensional Materials. Journal of ACS NANO, Vol. (9), NO. 11, 10612–10620.

[4] Oyedele, Akinola D., et al. Journal of the American Chemical Society (2017)

[5] Singh, Deobrat, et al. "2D-HfS 2 as an efficient

photocatalyst for water splitting." Catalysis Science & Technology 6.17 (2016): 6605-6614.



